Supplementary Information for

Kinetics of Dimethyl Sulfide (DMS) Reactions with Isoprene-derived Criegee Intermediates Studied with Direct UV Absorption

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S1 Summary of the experimental conditions and results

Table S1. Summary of the experimental conditions and results for the reaction CH₂OO+DMS at 308 nm photolysis. T = 296.8-297.2 K; $[O_2] = (3.28-3.32) \times 10^{17} \text{ cm}^{-3}$; $P_{\text{total}} = 299.9-301.5$ Torr.

Exp#	$[CH_2I_2]$	I _{308nm}	k_0	$k_{ m DMS}$	
	$/10^{13} \text{ cm}^{-3}$	$/\mathrm{mJcm}^{-2}$	$/s^{-1}$	$/10^{-16} \text{ cm}^3 \text{s}^{-1}$	
1	16.1	1.19	232±2 ^a	7.8±4.1 ^a	
2	16.3	2.35	464±3	10.9±5.6	
3	16.2	3.63	698±3	22.0±5.5	
4	16.5	4.83	956±5	-4.1±10.4	
5	12.6	0.34	54±2	9.1±4.5	
6	21.2	0.31	79±2	10.2±4.1	
7	20.7	0.31	90±2	8.6±4.9	
8	21.1	0.74	188±1	-3.2 ± 1.7	
9	19.6	0.95	240±2	12.0±3.5	
10	2.30	9.97	261±8	28.7±16.7	
11	25.4	2.27	680±4	24.1±8.2	
		avera	11.5		
		standard d	10.3		

^a averaged value ± 1 sigma error of the mean (statistical only, not including systematic errors). Note: 1 sigma error of the mean = standard deviation / sqrt(degrees of freedom)

Table S2. Summary of the experimental conditions and results for the reaction CH₂OO+DMS at 248 nm photolysis. T = 296.7K - 296.8 K; $[O_2] = 3.29 \times 10^{17} \text{ cm}^{-3}$; $P_{\text{total}} = 299.5 - 299.7 \text{ Torr.}$

Exp#	$[CH_2I_2]$	$I_{248\mathrm{nm}}$	k_0	$k_{ m DMS}$
	$/10^{13}~cm^{-3}$	$/mJ cm^{-2}$	$/s^{-1}$	$/10^{-16} \text{ cm}^3 \text{s}^{-1}$
12	19.3	1.10	109±1 ^a	16.2±10.3 ^a
13	19.0	2.18	197±1	25.5±8.6
14	18.9	3.17 275±1		31.6±11.5
		avera	24.4	
		standard de	7.8	

 $[^]a$ averaged value \pm 1 sigma error of the mean (statistical only, not including systematic errors). Note: 1 sigma error of the mean = standard deviation / sqrt(degrees of freedom)

^b Standard deviation of the 11 data points of k_{DMS} .

^b Standard deviation of the 3 data points of k_{DMS} .

Table S3. Summary of the experimental conditions and results for the reaction MVKO + DMS at 248 nm photolysis. T = 297.0 - 298.1 K; $[O_2] = (3.28 - 3.41) \times 10^{17} \text{ cm}^{-3}$.

Exp#	Precursor Abs	$P_{ m total}$	I _{248nm}	$k_{ m r}$	adduct yield $1-\alpha$	k_0	$k_{ m DMS}$
		/Torr	/mJ cm ⁻²	$/s^{-1}$	/0/0	$/s^{-1}$	$/10^{-16} \text{ cm}^3 \text{s}^{-1}$
15	0.100	301.4	1.09	1182±14 ^b	91.8±0.3 ^b	115±2 ^b	116.5±34.3 ^b
16	0.220	303.0	1.06	1442±7	89.2±0.1	151±2	94.7±34.5
17	0.331	301.6	1.03	1641±5	87.2±0.1	182±2	73.2±24.0
18	0.334	301.9	0.58	1386±10	90.4±0.2	140±1	99.9±19.1
19	0.056	302.1	1.25	1033±48	91.1±1.6	123±8	75.0±70.7
20	0.151	302.2	1.23	1109±14	91.2±0.3	131±2	44.2±22.5
21	0.057	302.5	2.45	1203±14	90.6±0.2	146±2	19.6±17.0
22	0.158	302.3	2.43	1395±6	87.0±0.1	179±5	78.7±56.1
23	0.056	302.3	3.72	1330±5	88.9±0.3	229±2	33.2±15.9
24	0.160	302.4	3.67	1652±8	84.0±0.1	274±1	-15.0 ± 16.7
25	0.179	30.6	1.19	1297±7	57.0±0.2	138±2	70.3±58.1
26	0.558	30.2	1.14	2123±19	49.2±0.1	255±2	67.8±59.3
27	0.289	100.2	1.18	1481±12	79.2±0.2	153±1	68.4±7.7
28	0.746	99.9	1.11	2146±8	70.7±0.1	321±2	39.6±25.8
29	0.142	299.5	1.19	1362±11	88.7±0.1	126±1	57.1±14.8
					average		61.6
					standard deviation ^c		33.4

^a The estimated absorbance of the precursor (1,3-diiodo-2-butene) at 238 nm in the photolysis reactor (using L = 426 cm).

Note: 1 sigma error of the mean = standard deviation / sqrt(degrees of freedom)

 $^{^{}b}$ averaged value \pm 1 sigma error of the mean (statistical only, not including systematic errors).

^c Standard deviation of the 15 data points of k_{DMS} .

S2 Observed decay rate coefficient of CH₂OO at various conditions

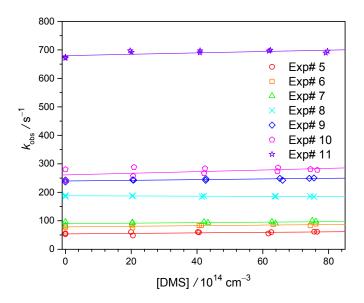


Fig. S1. First-order decay rate coefficient of CH₂OO, k_{obs} , against [DMS] at various experimental conditions (Exp#5–11, Table S1). The wavelength of the photolysis laser is 308 nm.

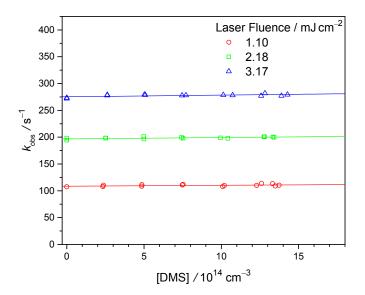


Fig. S2. First-order decay rate coefficient of CH_2OO , k_{obs} , against [DMS] at various photolysis laser fluence (Exp#12–14, Table S2). The wavelength of the photolysis laser is 248 nm.

S3 Kinetic model for MVKO reactions

To obtain more quantitative values for $k_{\rm DMS}$, we performed kinetic analysis with the following model. At t=0, the precursor ICH₂-CH=C(I)-CH₃ is photodissociated into CH₃(C₂H₃)CI + I. Under the high [O₂] conditions (~3.3x10¹⁷ cm⁻³) in our experiment, the reaction of CH₃(C₂H₃)CI + O₂ (R3a) and (R3b) proceeds within a very short time (< 0.1 ms). However, different from the case of CH₂OO, an additional MVKO signal rises slowly until about 2 ms (R3c), followed by a decay in longer reaction times (due to (R4) and (R5)). The formation/decomposition of the adduct of MVKO and I atom (R3b)/(R3c) are pressure dependent.

$$CH_{3}(C_{2}H_{3})CI + O_{2} \rightarrow I + CH_{3}(C_{2}H_{3})COO (MVKO)$$

$$(R3a; \alpha k_{O2})$$

$$CH_{3}(C_{2}H_{3})CI + O_{2} + M \rightarrow CH_{3}(C_{2}H_{3})CIOO + M$$

$$(R3b; (1-\alpha)k_{O2})$$

$$CH_{3}(C_{2}H_{3})CIOO + M \rightarrow I + CH_{3}(C_{2}H_{3})COO + M$$

$$(R3c; k_{r})$$

$$CH_{3}(C_{2}H_{3})COO (MVKO) + DMS \rightarrow Products$$

$$(R4; k_{DMS})$$

 $(R5; k_X)$

The detail kinetics of the adduct decomposition into MVKO + I will be published elsewhere. In brief, MVKO is either formed directly (R3a), or via the formation and consecutive decomposition of an adduct of $CH_3(C_2H_3)CIOO$ ((R3b) and (R3c)). From the differential rate equations of these three reactions, the following analytical expression for [MVKO](t) can be derived:

 $CH_3(C_2H_3)COO(MVKO) + X (radicals) \rightarrow Products$

$$[MVKO](t) = [MVKO]_{0}e^{-k_{obs}t} + [adduct]_{0}\frac{k_{r}}{k_{r} - k_{obs}}[e^{-k_{obs}t} - e^{-k_{r}t}]$$

$$= [MVKO]_{total}\{\alpha e^{-k_{obs}t} + (1 - \alpha)\frac{k_{r}}{k_{r} - k_{obs}}[e^{-k_{obs}t} - e^{-k_{r}t}]\}$$
(3)

with α and $(1-\alpha)$ as the yields of the prompt MVKO and the adduct ([MVKO]_{total} = [MVKO]₀ + [adduct]₀) and $k_{obs} = k_0 + k_{DMS}$ [DMS] as in the case of CH₂OO. Fitting this equation to the measured absorbance–time profiles treating k_{obs} , k_r , and α as variable parameters, we obtained k_{obs} . Selected results of k_{obs} are presented in Figure 4 and all results are summarized in Table S3.

S4 Observed decay rate coefficient of MVKO at various conditions

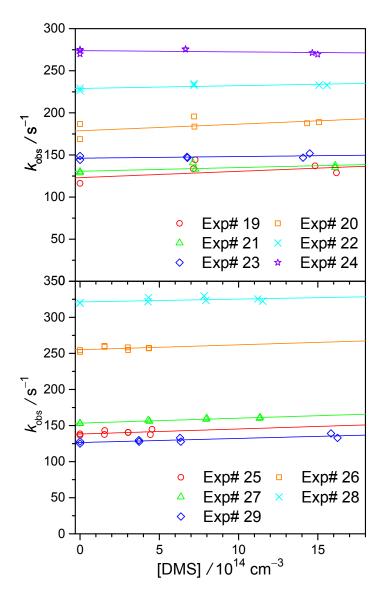


Fig. S3. First-order decay rate coefficient of MVKO, $k_{\rm obs}$, against [DMS] at various experimental conditions (Exp#19–29). The wavelength of the photolysis laser is 248 nm.

S5 Effect of DMS photolysis

Assuming the photolysis yield of DMS is unity, the concentration of the photodissociated DMS, [DMS]_{diss}, can be deduced from the following equation:

$$[DMS]_{diss} = [DMS]\rho\sigma$$

$$\rho = I\frac{\lambda}{hc}$$

where $\rho = I\lambda/hc$ is the number of photons per unit area and σ is the absorption cross section of DMS; I and λ are the fluence and wavelength of the photolysis laser; h and c are the Planck constant and speed of light, respectively. The maximum values of photodissociated DMS and CH_2I_2 precursor are estimated as in Table S4.

Table S4. Estimation for the photodissociated DMS and CH₂I₂.

Wavelength	I / mJ cm ⁻²	ho / cm ⁻²	σ / cm ²	[DMS] _{diss} /[DMS]	[DMS] /cm ⁻³	[DMS] _{diss} /cm ⁻³
248 nm	3.72	4.64×10^{15}	1.28×10^{-20}	5.9×10 ⁻⁵	1.7×10 ¹⁵	1.0×10 ¹¹
308 nm	9.97	1.55×10^{16}	$<1\times10^{-22}$	$<1.5\times10^{-6}$	8.1×10^{15}	$<1.3\times10^{10}$
				$[CH_2I_2]_{diss}/[CH_2I_2]$	$[CH_2I_2] / cm^{-3}$	$[CH_2I_2]_{diss}$ $/cm^{-3}$
248 nm	3.17	3.96×10^{15}	1.6×10^{-18}	6.3×10^{-3}	1.9×10^{14}	1.2×10^{12}
308 nm	9.97	1.55×10^{16}	3.3×10^{-18}	5.1×10^{-2}	2.3×10^{13}	1.2×10^{12}

High [DMS]_{diss} at 248 nm photolysis would generate radical products, which may react with CH₂OO or MVKO and may absorb light at our probe wavelength (see **Figure S4**). On the other hand, the very minor [DMS]_{diss} at 308 nm photolysis would not cause a problem. Hence, at 248 nm photolysis, we limit [DMS] $\leq 1.7 \times 10^{15}$ cm⁻³ and $I_{248\text{nm}} \leq 3.72$ mJ cm⁻² (Exp#23–24) to constraint [DMS]_{diss} $\leq 1.0 \times 10^{11}$ cm⁻³. **Figure S5** shows the background trace at 248 nm photolysis with constraint [DMS] and $I_{248\text{nm}}$. No significant background due to [DMS]_{diss} is observed, except absorption caused from the optics. Besides, in **Figure S9**, we can see that the results of CH₂OO+DMS reaction at 248 nm photolysis are quite similar to those at 308 nm, while a slightly higher k_{DMS} can be observed for 248 nm at high $I_{248 \text{ nm}}$, indicating that [DMS]_{diss} only has a minor effect.

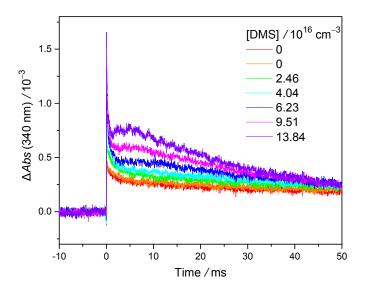


Fig. S4. Background traces recorded under extra-high [DMS]. The traces were obtained with 248 nm photolysis laser ($I_{248\text{nm}} = 3.34 \text{ mJ cm}^{-2}$). The experimental conditions are : $P_{\text{total}} = 297.2 \text{ Torr}$, [O₂] =3.23 x10¹⁷ cm⁻³, T=299K. The length of the cell for monitoring [DMS] is 1 cm. The photolysis laser pulse defines t=0. The absorbance change under zero [DMS] comes from the interaction of the optics and the photolysis laser pulse. Note that in the kinetic experiments, the used [DMS] was much lower ($< 1.7 \times 10^{15} \text{ cm}^{-3}$) such that the background did not depend on [DMS] (see Figure S5).

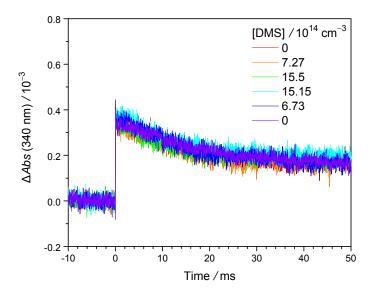


Fig. S5. Background traces under normal DMS concentrations obtained with 248 nm photolysis laser ($I_{248\text{nm}} = 3.72 \text{ mJ cm}^{-2}$). See Exp# 23 of Table S3 for the experimental condition.

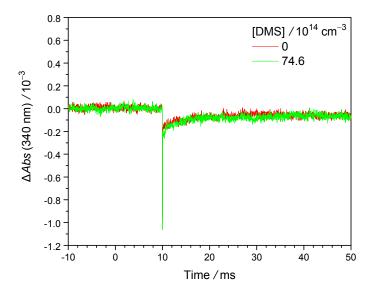


Fig. S6. Background traces under various [DMS] obtained with 308 nm photolysis laser ($I_{308\text{nm}} = 4.83 \text{ mJ cm}^{-2}$). See Exp#4 of Table S1 for the experimental condition. Note that the optics (long pass filters) are different from those at 248 nm.

S6 Dependence of k_0 and k_{DMS} on laser fluence and precursor concentration

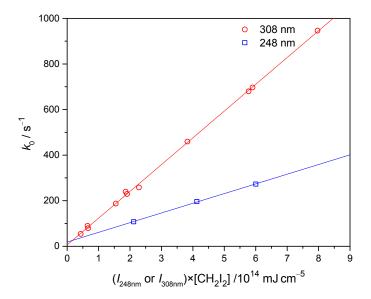


Fig. S7. Plot of k_0 against the product of the laser fluence (I_{248nm} or I_{308nm}) and the precursor concentration [CH₂I₂] for the experiments (Exp#1–14, Tables S1–S2) of CH₂OO+DMS reaction. The x-axis essentially represents the total amounts of radical species generated through the photolysis of the precursor (R1) and the subsequent reactions (R2). Higher radical concentration results in faster CH₂OO decay, thus higher k_0 . The difference of the slopes mainly comes from the difference of CH₂I₂ absorption cross sections at these two wavelengths (see Table S4). Note that there are experiments having different combinations of [CH₂I₂] and I_{308nm} , but very similar I_{308nm} x[CH₂I₂] (like Exp#3,11; Exp#1,9).

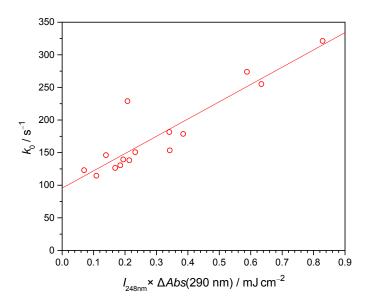


Fig. S8. As Figure S7, but for the experiments (Exp#15–29) of MVKO+DMS reaction. Because the absorption cross section of the precursor is not available, we use its absorbance to represent its concentration.

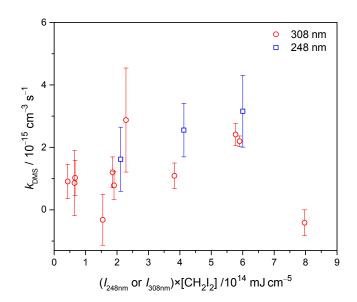


Fig. S9. Plot of $k_{\rm DMS}$ against the product of the laser fluence ($I_{248\rm nm}$ or $I_{308\rm nm}$) and the precursor concentration [CH₂I₂] for the experiments (Exp#1–14, Tables S1–S2) of CH₂OO+DMS reaction. The x-axis essentially represents the total amounts of radical species generated through the photolysis of the precursor (R1) and the subsequent reactions (R2). No observable trend of $k_{\rm DMS}$ can be found for the data of 308 nm photolysis, whereas $k_{\rm DMS}$ at 248 nm photolysis increases as $I_{248\rm nm}$ x[CH₂I₂] increases, which may result from the increased radical generation from the DMS photolysis. Note that there are experiments having different combinations of [CH₂I₂] and $I_{308\rm nm}$, but very similar $I_{308\rm nm}$ x[CH₂I₂] (like Exp#3,11; Exp#1,9).

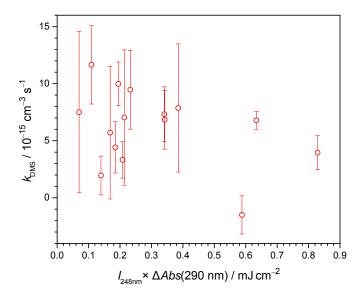


Fig. S10. As Figure S9, but for $k_{\rm DMS}$ in Exp#15–29 of MVKO+DMS reaction. No significant trend for $k_{\rm DMS}$ is observed.

S7 Representative time traces for the $CH_2OO+DMS$ reaction obtained with 308 nm photolysis

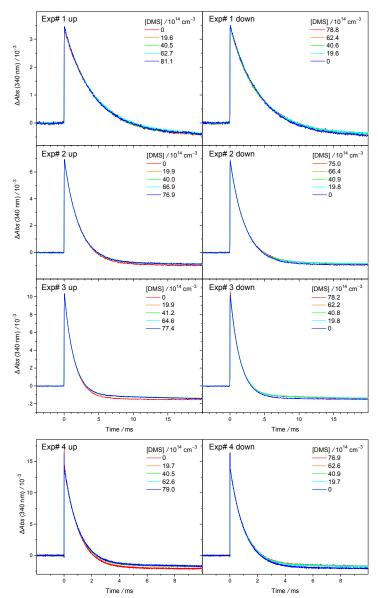


Fig. S11. Representative time traces of CH_2OO absorption at 340 ± 5 nm at various [DMS] (Exp#1–4). The wavelength of the photolysis laser was 308 nm and the laser pulse is set at the time zero. In each experiment, [DMS] was scanned from 0 to the maximum (labeled as "up"), and scanned from maximum to 0 (labeled as "down"). The negative baseline is resulted from the depletion of the precursor CH_2I_2 .

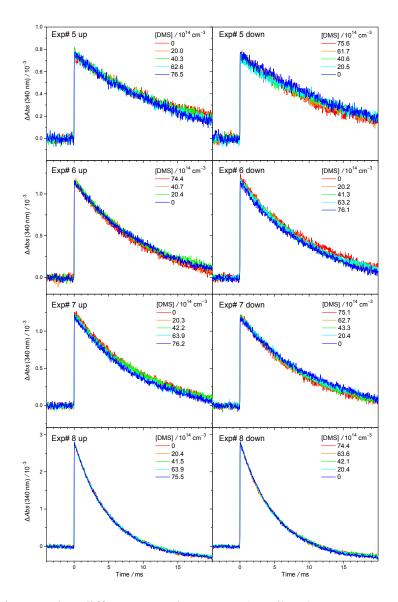


Fig. S12. As Fig. S11, but different experiment sets (Exp#5-8)

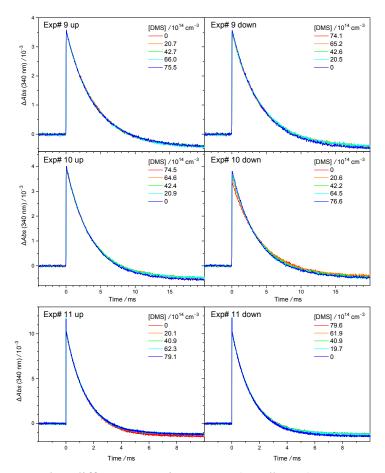


Fig. S13. As Fig. S11, but different experiment sets (Exp#9-11)

S8 Representative time traces for the $CH_2OO+DMS$ reaction obtained with 248 nm photolysis

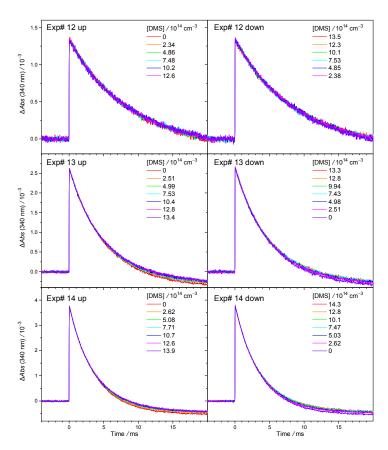


Fig. S14. Representative time traces of CH_2OO at 340 ± 5 nm at various [DMS] (Exp# 12–14). The wavelength of the photolysis laser was 248 nm and the laser pulse is set at the time zero. In each experiment, [DMS] was scanned from 0 to the maximum (labeled as "up"), and scanned from maximum to 0 (labeled as "down"). The negative baseline resulted from the depletion of the precursor CH_2I_2 .

S9 Representative time traces for the MVKO+DMS reaction obtained with 248 nm photolysis

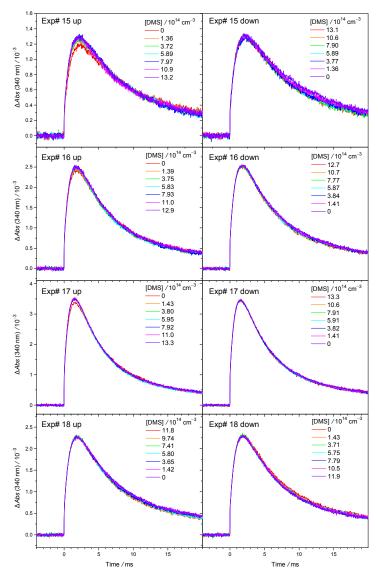


Fig. S15. Representative time traces of MVKO at 340±5nm at various [DMS] (Exp#15–18). The wavelength of the photolysis laser was 248 nm and the laser pulse is set at the time zero. In each experiment, [DMS] was scanned from 0 to the maximum (labeled as "up"), and scanned from maximum to 0 (labeled as "down").

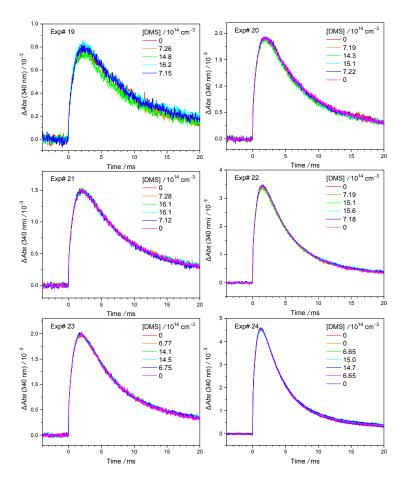


Fig. S16. Representative time traces of MVKO at 340±5nm at various [DMS] (Exp#19–24). The wavelength of the photolysis laser was 248 nm and the laser pulse is set at the time zero.

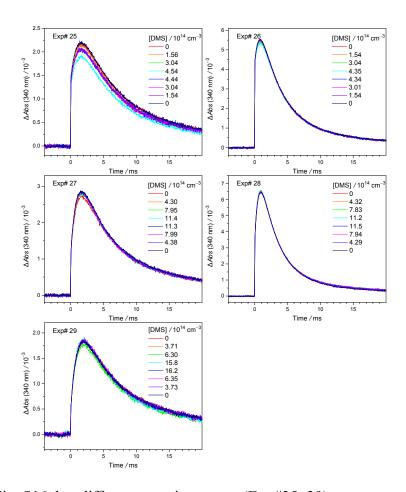


Fig. S17. As Fig. S16, but different experiment sets (Exp#25-29)

S10 Computational details for the reaction of CH₂OO + DMS

Additional methodological information

The CH₂OO + DMS system was characterized at the CCSD(T)/aug-cc-pVTZ//M06-2X/ aug-cc-pV(T+d)Z level of theory. Though the computational demands of the reaction system prevent us from doing higher-level calculations at this time, this level of theory is expected to be sufficient to give a good idea of the PES layout, and derive rate coefficients with an accuracy of about one to two orders of magnitude. In particular, the study by Newland et al. (2015) proposes a very fast reaction which should then have a low energy barrier, whereas the current experimental study finds very slow elementary reactions which perforce must have a high energy barrier. The level of theory applied is able to easily discriminate between these extreme cases.

An additional set of exploratory calculations were performed at the M06-2X/cc-pVDZ level of theory, specifically on DMS + larger CI, DMS + CH₂OO in the presence of O₂, and unimolecular reactions of CH₂OO, *syn*-CH₃CHOO, *anti*-CH₃CHOO, and *cyc*-CH₂OOS(O)O-with and without complexation with DMS. These calculations at lower level are discussed here in the supporting information. For these calculations, only relative barrier heights on analogous reactions are important, which are sufficiently well described at the level of theory employed. As no indication for a significant enhancing effect on the reaction rate was found, no attempt was made to improve the absolute barrier heights.

Impact of substitutions of the CI, or the presence of O₂, on the CI + DMS reaction

Calculations for $CH_2OO + DMS + O_2$ reveal no influence of O_2 as a reaction partner, though the $(CH_3)_2SCH_2OO$ adduct may form a complex with O_2 stabilized by few kcal mol^{-1} . O_2 addition on the $(CH_3)_2SCH_2OO$ and $CH_3S(=CH_2)CH_2OOH$ adducts, forming triplet peroxy radicals, was found to have large barriers exceeding 15 kcal mol^{-1} , and is not competitive against redissociation of the CI+DMS adducts even at atmospheric O_2 concentrations.

Calculations on the reactions of *syn*-CH₃CHOO and *anti*-CH₃CHOO with DMS show that, as opposed to the CH₂OO case, formation of (CH₃)₂SCH(CH₃)OO adducts is endothermic by a few kcal mol⁻¹, making reaction of substituted CI with DMS even less favorable. This conclusion is expected to hold also for the MVKO CI.

DMS as a catalyst

The experiments of Newland et al. (2015) found no evidence of DMS consumption, suggesting that the DMS activity hampering SO₂ oxidation by CI in their isoprene + O₃ system might be caused by catalytic effects. Hence, we examined whether the unimolecular decay of CI could be affected by complexation with DMS, performing a set of calculations using the lower level M06-2X/cc-pVDZ level of theory. At that level of theory, the complexes of CH₂OO,

syn-CH₃CHOO and anti-CH₃CHOO with DMS are stabilized by 8.5 to 10.9 kcal mol⁻¹ (likely overestimated due to basis set superposition errors). The barriers for dioxirane formation in CH₂OO, syn-CH₃CHOO and anti-CH₃CHOO are 22.0, 25.8 and 18.4 kcal mol⁻¹ without DMS, respectively, while in the DMS complex they are 24.1, 26.8 and 20.4 kcal mol⁻¹ above the complex, respectively. In syn-CH₃CHOO, the energy barrier for 1,4-H-migration (vinylhydroperoxide channel) without and with DMS are 12.7 and 15.8 kcal mol⁻¹, respectively, again calculated from the bottom of the CI-DMS complex. These results, despite being at a less reliable level of theory, strongly suggest that the DMS complexation does not lower the intrinsic barriers for unimolecular rearrangements, and might even slightly increase them. Any catalytic effect of DMS on the unimolecular decomposition of CI is then due to the energy release of the complexation, but this is insufficient to lower the decay TS close to or below the energy level of free CI + DMS, such that the main fate of the complex remains redissociation without chemical loss. This is in agreement with the observations of the current experimental study, which sees no enhanced CI loss in the presence of DMS.

There are many other reactions in the isoprene + O_3 system that might be catalytically enhanced or slowed by DMS, and examining all of these is outside the scope of this study. We did examine the reaction of DMS with the adduct of $CH_2OO + SO_2$, *i.e.* the thio-secondary ozonide (cyc- $CH_2OOS(O)O$ -, thio-SOZ) (Kuwata et al., 2015; Vereecken et al., 2012) formed prior to its decomposition to $SO_3 + CH_2O$. The DMS-catalyzed redissociation of thio-SOZ back to $CH_2OO + SO_2$, thus inhibiting SO_2 oxidation by CI, was found at the M06-2X/cc-pVDZ level of theory to have an energy barrier of 17.8 kcal mol^{-1} , too high to compete against SO_3 formation for which a barrier ≤ 10 kcal mol^{-1} was found (Kuwata et al., 2015). Any inhibiting effect by DMS on the $CI + SO_2$ reaction is thus not caused by an enhanced redissociation of the thio-SOZ intermediate.

No data is available elucidating whether bimolecular reactions of CI-DMS complexes with suitable co-reactants (SO₂, H₂O, acids,...), or alternatively DMS complexes of such co-reactants with free CI, are hindered or enhanced relative to those of the free CI + co-reactant.

References

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